

# Reliability Report

IXD\_602 Series VIS Foundry; Process CU05UMS12010 (ASSEMBLY IN SOIC STYLE PACKAGES)

**Report Title: Reliability Summary Report** 

IXD\_602 Series VIS Foundry Process CU05UMS12010

**SOIC Style Package Assembly** 

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## **Introduction:**

This report summarizes the Reliability data of IXYS IC Division IXD\_602 product family in SOIC style packages. The Reliability data presented here were collected from multiple sources including internal product qualifications, external subcontracted test and reliability facilities and internal reliability monitors. The IXD\_602 family of Gate Driver products is foundered at Vanguard International Semiconductor, Corp. (VIS) and assembled at CEI in Thailand and/or Atec in the Philippines. The VIS process is CU05UMS12010.

## **Reliability Tests:**

Table 1 below provides the reliability tests that were performed, the referenced industry specification and details on number of devices/lots per test.

## IXD\_602SI/SIA Product Reliability Tests

Stress Test	<b>Applicable Specs</b>	Stress Conditions	Number of Lots	Sample Size (SS)	Total SS
HTOL	JESD22-A104-C	1000hrs, 150°C	6	80	480
HTOL	Mil-Std-883	1000hrs. 125°C	2	77	154
HAST	JESD22- A110-C	130°C, 85% 18.8PSI, 96hrs	6/2	80/76	632
Thermal Shock	Mil-Std-883, M1011	0 to 100°C, 10/10 dwells, 15 cycles	1	55	55
Temp Cycle (T/C)	JESD22-A104-C	-65 to 150°C, 10/10 dwells, 250 cycles	1	55	55
High Temp Storage	JESD22-A103C	150°C, 1000hrs	3	50	150
Autoclave	J-STD-020D.1, JESD22- A102	T=121°C, RH=100% t=96hrs unbiased	6	80	480
Latch Up	AECQ100- 003	T=125°C, 35v, 100mA	1	8	8
MSL	J-Std-020	IR reflow; Level 1 3x	1	50	50

Stress	<b>Applicable Specs</b>	Stress	Number	Sample	Total
Test		Conditions	of Lots	Size (SS)	SS
	Gate	T=RT	1	8	8
	Leakage				
ELFR	AECQ100-	T=150°C, t=48hrs	2	800	1600
	008-REV A	With bias			
PTC	JESD22-	T=-40°C/+125°C,	1	48	48
	A105-C	1000 cycles			
		t=45 min			
ESD	JESD22-	1.5kΩ, 100pF	2/1	9/25	43
HBM	A114-E	•			

## **Reliability Test Results:**

The stress tests and associated results for the reliability analysis of product IXDx602SI/SIA are summarized in Table 2. The devices chosen for the qualification were from standard material manufactured through normal production test flow and electrically tested to datasheet limits prior to stressing. Products selected for the data summary share identical wafer fabrication processes, the same subcontractor assembly locations and all materials related to assembly are identical. Then reliability stresses were conducted and electrically tested to datasheet limits at each interval and final readpoint.

Table 2: Product IXD\_602 Family Reliability Test Results

Stress Test	Readpoint / (Reject/ SS)
HTOL 150°C	1000 hrs/ 0 / 480
HTOL 125°C	1000 hrs/ 0 / 154
HAST	96 hrs/ 0 /632
Thermal Shock	15 cycles/ 0 /55
Temp Cycle	250 Cycles/ 0 / 55
High Temp Storage	1000 hrs/ 0 / 150
Autoclave	96 hrs / 0 / 480

Stress Test	Readpoint / (Reject/ SS)
MSL; IR Reflow 3X	Level 1, 3x/ 0/50
Latch-Up	Trigger Pulse
	0/8
Gate Leakage	Neg./Pos.
	Potential
	0/8
ELFR	48 hrs.
	0/1600
PTC	1000 cycles
	0/48

## **ESD Testing Results:**

As part of this reliability testing, the IXD\_602 product family was subjected to Human Body Model (HBM) ESD Sensitivity Classification testing using a KeyTek Zapmaster system. The results are summarized in Table 3. All samples were electrically tested to data sheet limits before and after ESD stressing and they passed after +/-3000V testing.

**Table3: Product IXDI602SIA ESD Characterization Results** 

ESD Model	Package	ESD Test Spec	RC Network	Highest Passed	Class
HBM	SOIC – 8L	JESD22, A114-E	1.5kΩ, 100pF	3000V	2

# FIT (Failure in Time) Rate on the IXD\_602 Product Family

Table 4 summarizes the number of devices used for IXD\_602 product family reliability stress. Using the HTOL data, FITs were calculated based on the Acceleration Factor (AF) and equivalent device hours at 0.7eV of activation energy for 150°C test temperature and 40°C use temperatures. Using the HAST data, FITs were calculated based on the Acceleration Factor (AF) and equivalent device hours at 0.7eV of activation energy for 130°C test temperature and 40°C use temperatures.

## Table 4: Product Family IXD\_602SI (SOIC style package data) FIT Rate Summary

(HTOL results were calculated using the higher temperature results at 150 degrees only)

Stress	# of	# of	Hours		Acceleration	Equivalent	FIT Rate
	Devices	Fails	Tested	Energy	Factor	Dev. Hours	@ 60% CL
HTOL	480	0	1000	0.7	853.34	409,605,288	2.25
HAST	632	0	96	0.7	1.4318E+03	904,888,485	1.02